

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	63742	((silicon\$4 OR Si) NEAR3 on NEAR3 insulat\$4) OR SOI	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/12 15:37
L3	1392	L1 AND ((hard\$4 NEAR2 mask\$4) OR hard\$1mask\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/12 15:41
L4	703	L3 AND (Box OR (bur\$4 NEAR20 oxide))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/12 15:42
L5	8	L4 AND ((HBr OR (hydrogen\$4 ADJ bromi\$4))NEAR20 ("NF.sub.3" OR (nitrogen\$4 ADJ trifluori\$4)) NEAR20 (oxygen\$4 OR "O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/12 15:56
L8	8	L5 AND (trench\$4 NEAR20 etch\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/12 15:57
L9	5	L5 AND (trench\$4 NEAR20 etch\$4)	US-PGPUB	OR	OFF	2005/09/12 15:58
L10	5503	((216/47,51,67,74,79,80) or (438/717,719,723,724,735,736,737,738,743)).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/09/12 15:58
L11	0	L10 AND L8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/12 15:58